WEST Search History

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DATE: Thursday, January 20, 2005

Hide?	Set Name	Query	Hit Count
		DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
☐	L9	L8 and l5	18
☐	L8	134/1.3,3,26,28,30.ccls.	5972
		DB=EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ	
☐	L7	((wafer or substrate or semiconductor) with (clean$3 or remov$3 or treat$3)) same water same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2') same $5sonic$5	9
☐	L6	L5	0
		DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
☐	L5	L4	45
		DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ	
☐	L4	((wafer or substrate or semiconductor) with (clean$3 or remov$3 or treat$3)) same water same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2') same $5sonic$5	54
☐	L3	L1 same water same (ozone or 'O.sub.3') same (hydrogen or 'H.sub.2') same $5sonic$5	1
☐	L2	L1 same (water with (ozone or 'O.sub.3') with (hydrogen or 'H.sub.2') with $5sonic$5)	0
☐	L1	(wafer or substrate) with (bare or silicon oxide or 'SiO.sub.2') with (clean$3 or remov$3 or treat$3)	11671

END OF SEARCH HISTORY